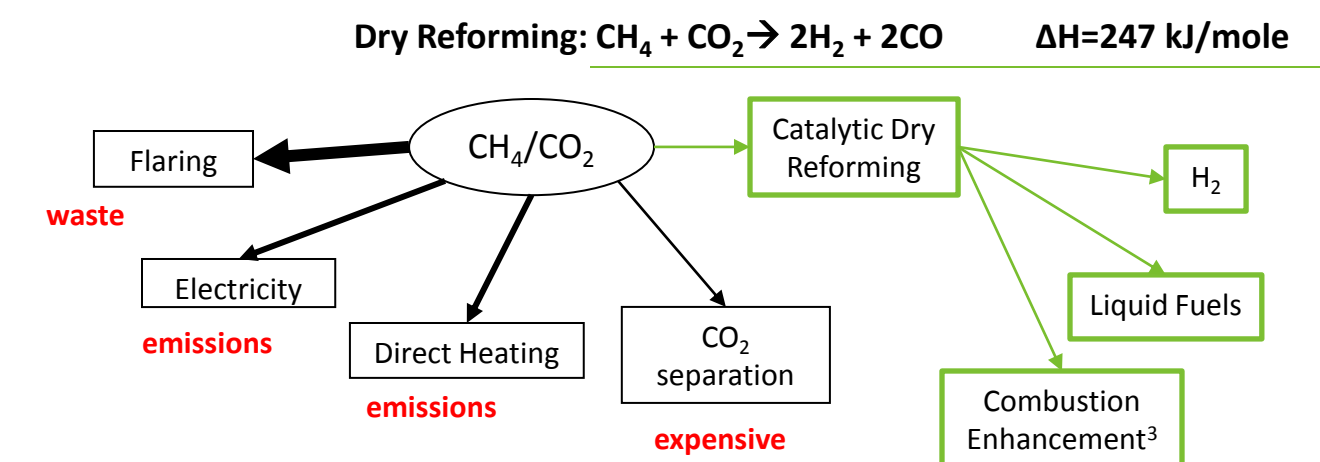


Motivation

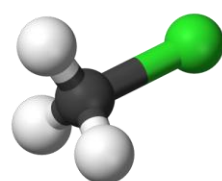
- CH₄/CO₂ mixtures such as landfill gas, biogas, and wastewater digester gas are relatively small scale but local and cheap sources of energy
- They are most often flared due to the low energy content¹, but dry reforming can make use of the entire mixture²:



- These CH₄/CO₂ mixtures may contain poisons that could deactivate a catalyst:

Class	Examples	Amount (PPMV)
Chlorinated	Vinyl Chloride, Chlorocarbons	10-50
Sulfur	Hydrogen Sulfide, Methyl Sulfide	30
Aromatic	Toluene, Benzene	100
C2s	Ethane, Ethanol	70
C3s	Propane, Acetone	30

Chlorocarbons originate from natural presence of chlorinated compounds in biological material.

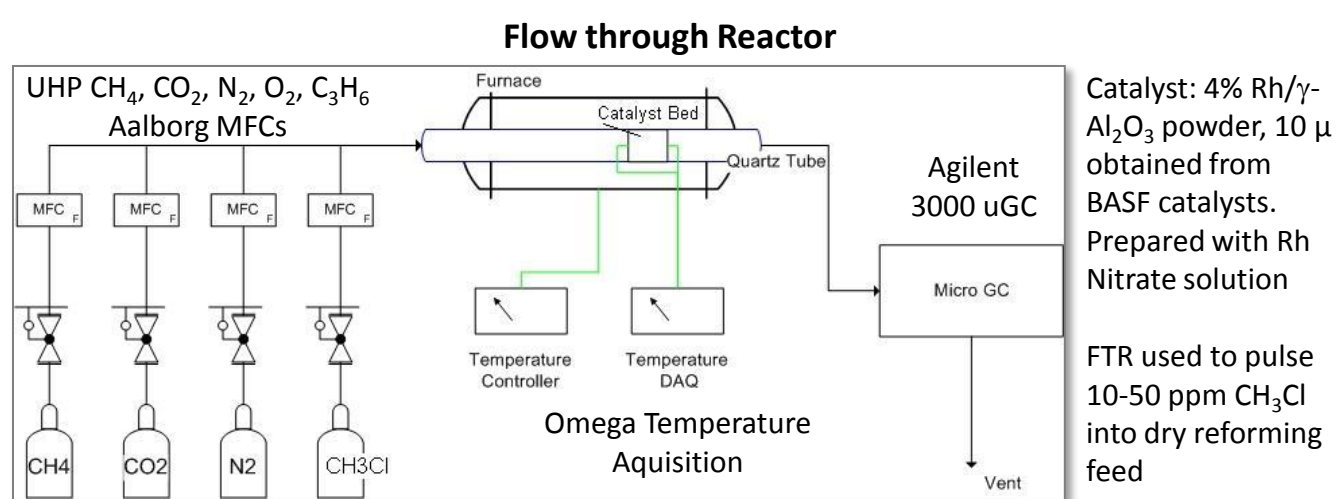


Typical poisons in a landfill gas¹

- Aromatics and hydrocarbons result in carbon formation that can be countered with additional oxidant
- Sulfur is extensively studied

- No studies to our knowledge on effect of chlorocarbon on dry reforming**
- As use of bio-derived fuels becomes more widespread, effect of chlorocarbons on reforming catalysts will become more important**

Experimental Setup

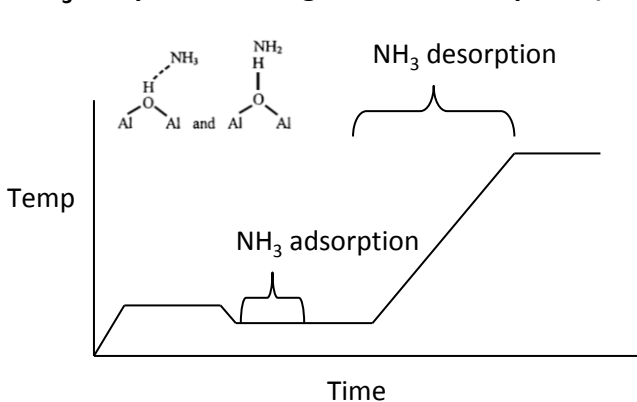


Characterization

Samples prepared for characterization:

Name	Reforming Feed	[CH ₃ Cl]	Temp °C	Reaction Time
400°C, 10hr	5% CH ₄ , 6% CO ₂	0	400	10 hours
400°C, 10hr, w/Cl	5% CH ₄ , 6% CO ₂	50 ppm	400	10 hours
700°C, 10hr	5% CH ₄ , 6% CO ₂	0	700	10 hours
700°C, 10hr, w/Cl	5% CH ₄ , 6% CO ₂	50 ppm	700	10 hours

NH₃ Temperature Programmed Desorption (TPD)



XPS: Thermo Fisher K Alpha XPS equipped with an Al K(alpha) monochromatic source. Binding energies referenced to C1s=285.0 eV

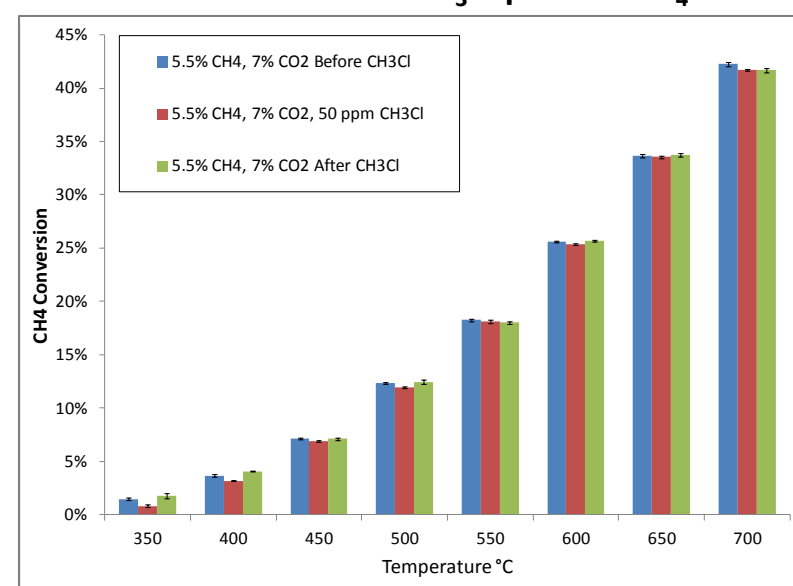
CO₂ chemisorption: TGA (Netzsch, STA 409 PC Luxx) used to measure weight gain during CO₂ adsorption to measure surface basicity

CO chemisorption: TGA used to measure weight gain during CO adsorption to measure available metal sites

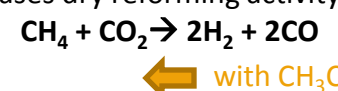
BET: Quantachrome Nova 2200e

Effect of CH₃Cl on Activity, Selectivity

CH₃Cl poisons CH₄ reforming activity



- 1 hour 50 ppm pulse of CH₃Cl into dry reforming feed reversibly decreases dry reforming activity:

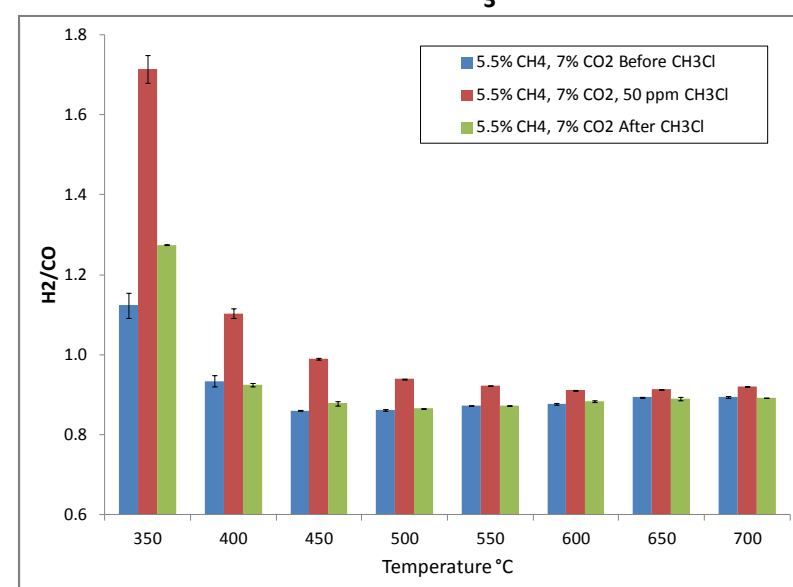


ΔH=247 kJ/mole

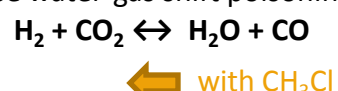
- Syngas production drops commensurately with loss of CH₄ reforming

- Poisoning is greatest at low temperatures (350-500°C)

CH₃Cl increases selectivity to H₂



- Change in selectivity indicative of reverse water-gas shift poisoning:



ΔH=42 kJ/mole

- During CH₃Cl pulse, CO₂ and H₂ increase, H₂O and CO decrease

- HCl pulse gives same change in selectivity as CH₃Cl, indicating chloride is key species

CH₃Cl introduction reversibly poisons dry reforming and reverse water-gas shift reactions, especially at low temperatures

Surface Characterization

XPS shows surface chloride deposition is highest at low temperatures

Known Binding Energies from NIST ⁴ and Literature ^{5,6}		
Orbital	B.E. eV	Species Name
Rh3d5	309.4	rhodium oxide
	310.0	diffuse rhodium oxide
	310.1	rhodium chloride
Cl2p	198.0, 198.4	alumina hydroxide-chloride ⁶
	198.3	Al-Cl ⁵
	198.6	rhodium chloride
	199.1	alumina oxi-chloride ⁶
	199.3	rhodium chloride

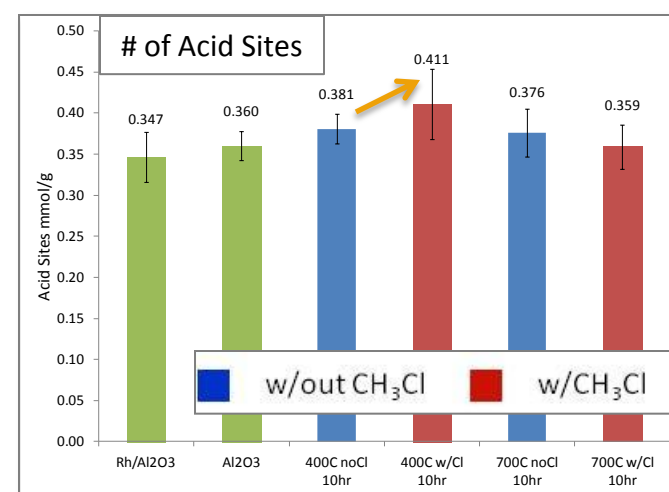
- Location of chloride is not definitive because binding energies for related species are similar

- Chloride deposition decreases with temperature; little effect of time on stream

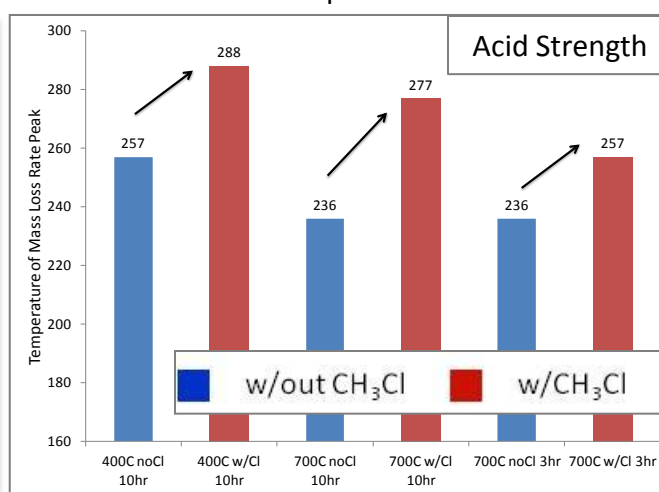
Sample	Chloride Wt %
400°C, 10 hr, w/Cl	1.25
700°C, 3 hr, w/Cl	0.72
700°C, 10 hr, w/Cl	0.65

NH₃ TPD shows CH₃Cl increases acidity of catalyst surface

CH₃Cl exposure increases number of acid sites at 400°C



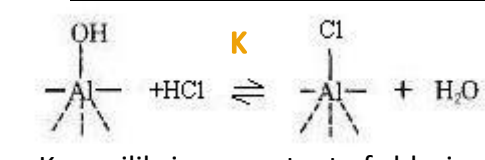
CH₃Cl exposure increases strength of acid sites at all temperatures



Mechanism and Model

Alumina chlorination model developed for Pt/γAl₂O₃ can be applied here

Alumina Chlorination Reaction⁷:



K=equilibrium constant of chlorination reaction

$$R = \frac{[\text{H}_2\text{O}]}{[\text{HCl}]}$$

$$L = [\text{Cl}] + [\text{OH}]$$

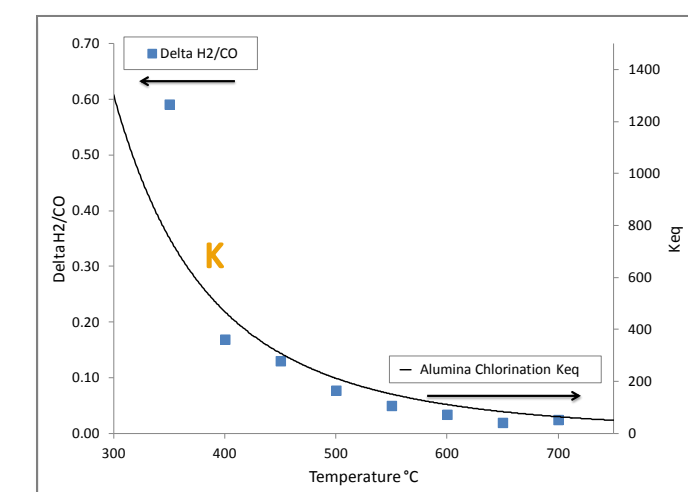
L=chloride retention capacity

Expression for Adsorbed Chloride:

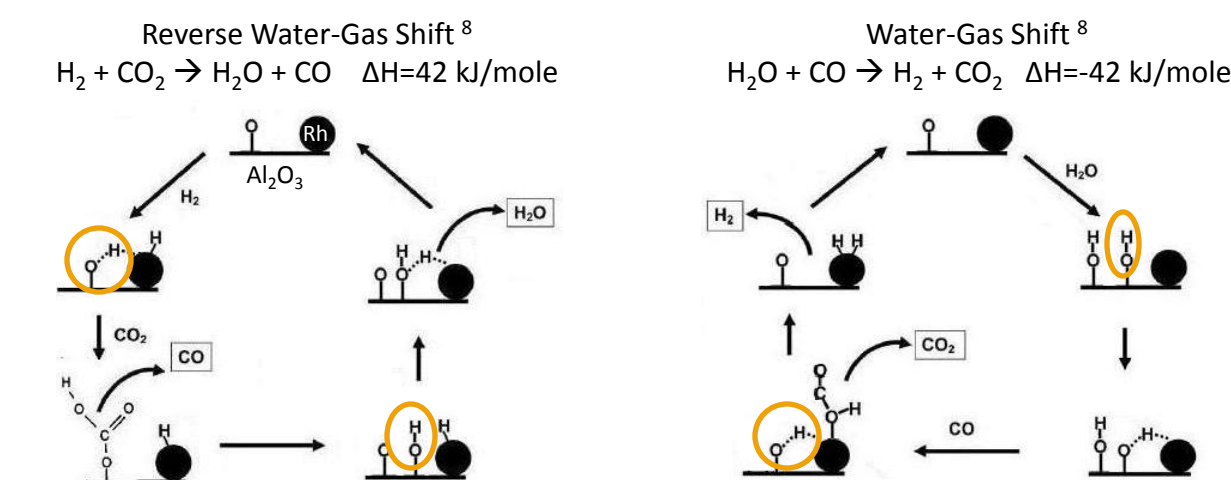
$$[\text{Cl}^*] = \frac{KL(1/R)}{1 + K(1/R)}$$

- K decreases with temperature, meaning chlorination is not favored at high temp

- K function correlates with experimentally observed selectivity change; means that alumina chlorination reaction could be valid on Rh/γAl₂O₃



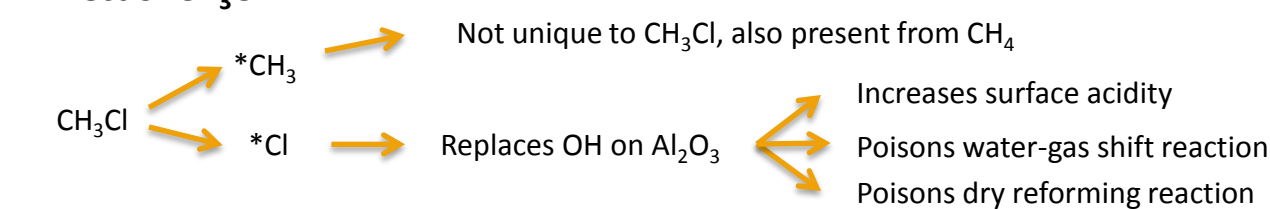
If alumina OH removal by chloride is a reasonable poisoning mechanism, change in selectivity can be explained, because forward and reverse water-gas shift reactions rely on OH groups:



- OH groups are likely intermediates in forward and reverse water-gas shift reactions
- Chloride replaces OH groups, so poisons water gas shift
- Mechanism for CO₂ activation in RWGS also important for dry reforming activity; could be cause for dry reforming activity loss as well

Conclusions and Recommendations

Effect of CH₃Cl:



- Co-feeding biogas with O₂ or H₂O decreases chloride poisoning

- Operating the reactor at a higher temperature decreases chloride poisoning

- Auto-thermal reforming is a good reforming option for LFG with chlorocarbons because it supplies H₂O to remove chloride deposition from alumina and O₂ to keep surface free of carbon

Acknowledgements

Thank you very much to the Combustion and Catalysis Lab, BASF, and Columbia University for their generous support of this research.

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